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Surface chemical analysis — Sample handling, preparation and mounting —

Part 2:

Documenting and reporting the preparation and mounting of specimens for analysis

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CP 401 • Ch. de Blandonnet 8
CH-1214 Vernier, Geneva
Phone: + 41 22 749 01 11
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Contents

Foreword v

Introduction vi

Part 2: Documenting and reporting the preparation and mounting of specimens for analysis 1

1 — Scope 1

2 — Normative references 1

3 — Terms and definitions 1

4 — Symbols and abbreviated terms 2

5 — Provenance information to be collected or retained 2

5.1 — Information record 2

5.2 — Verification or generation of sample information and analysis objectives 3

6 — Information about sample handling and preparation for analysis to be documented and added to the sample information record 3

6.1 — General 3

6.2 — Adherence or exceptions to the general sample handling requirements 3

6.3 — Description of ex situ sample handling 4

6.4 — Method of mounting samples for analysis 4

6.5 — In situ sample cleaning or other sample preparation or processing 5

6.6 — Post analysis handling and storage 5

Annex A (normative — Information about approaches, issues and good practices regarding sample handling and mounting in preparation for analysis) 6

A.1 — Introduction and overview 6

A.1.1 — General handling requirements for surface analysis 6

A.2 — Assessment and Planning 6

A.2.1 — Introduction 6

A.2.2 — Visual Inspection Before and After Analysis 7

A.2.3 — Analysis Order 7

A.2.4 — Differences in handling and mounting requirements for AES, XPS, SIMS and other Surface Analysis methods 7

A.2.5 — Sample charging issues 8

A.2.6 — Storage and Transfer Prior to Analysis 8

A.3 — Ex situ sample handling (e.g. cleaning, cutting/sectioning, polishing, or exposing the region of interest before insertion into the analysis chamber) 9

A.3.1 — Introduction and Overview 9

A.3.2 — Sample cleaning techniques 10

A.3.3 — Sectioning/cutting techniques - altering the size or shape of a sample 10

A.3.4 — Exposing the surface or buried interface of interest (ex situ) 11

A.3.5 — Sample coatings 12

A.4 — Mounting techniques 12

A.4.1 — Introduction 13

A.4.2 — General Procedures 13

A.4.3 — Powders and Particles 13

A.4.4 — Wires, Fibers, and Filaments 13

A.4.5 — Pedestal mounting 14

A.4.6 — Special Cases: gassy specimens, viscous liquids, solute residues, freezing samples 14

A.4.7 — Masking for charge control 14

A.5 — In situ sample cleaning or other sample preparation or processing to expose the region of interest 14

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ISO/~~DIS~~FDIS 20579-2:2024(en)

A.5.1	Sample Heating: Cleaning/Decontamination, Segregation Studies, Reactive Layer Formation	15
A.5.2	Ion sputtering and cluster cleaning	15
A.5.3	UV radiation	15
A.5.4	Fracturing, cleaving, and scribing in situ	16
A.5.5	Coatings and Growth of overlayers	16
A.5.6	FIB Cross sections and crater edge profiling	17
Annex B	(normative) Sources of contamination, sample handling and storage practices	18
B.1	Introduction	18
B.2	Potential Sources of contamination during handling	18
B.3	Handling procedures to minimize contamination	19
B.3.1	Introduction	19
B.3.2	Description of important generic sample handling requirements	19
B.3.3	Analysis objectives determine specific sample handling requirements	19
B.4	Storage requirements and needs	22
B.4.1	General	22
B.4.2	Storage time, temperature, and humidity	22
B.4.3	Containers	23
Bibliography	24
Foreword	v
Introduction	vi
1	Scope	1
2	Normative references	1
3	Terms and definitions	1
4	Symbols and abbreviated terms	2
5	Provenance information to be collected or retained	2
6	Information about sample handling and preparation for analysis to be documented and added to the sample information record	3
Annex A	(normative) Information on approaches, issues and good practices regarding sample handling and mounting in preparation for analysis	7
Annex B	(normative) Sources of contamination, sample handling and storage practices	20
Bibliography	27

Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular, the different approval criteria needed for the different types of ISO document should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

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This document was prepared by Technical Committee TC 201, *Surface Chemical Analysis*, Subcommittee SC 2, *General Procedures*.

This first edition of ISO 20579-~~part 2~~ cancels and replaces ISO 18116:2005, which has been technically revised.

A list of all parts in the ISO 20579 series can be found on the ISO website.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

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[Annex-B](#) provides information about sources of contamination, sample handling and storage requirements for differing analysis objectives.

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vii
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Surface chemical analysis — Sample handling, preparation and mounting —

Part 2: Documenting and reporting the preparation and mounting of specimens for analysis

1 Scope

This document ~~identifies~~specifies information to be reported by an analyst in a datasheet, certificate of analysis, report or other publication regarding the handling, preparation, processing and mounting of specimens for surface analysis. Appropriate sample handling with adequate documentation is ~~required~~needed to ensure and assess reliability and reproducibility of analyses. Such information is in addition to other details associated with specimen synthesis, processing history and characterization, and should become part of the data record (sometimes identified as provenance information) regarding the source of the material and changes that have taken place since it was originated.

This document also includes normative annexes that summarize important processes and common approaches relevant to sample preparation and mounting for surface analysis. The descriptions of procedures for which records and reporting are required follow the steps that an analyst would follow from receiving the samples, to cleaning or processing outside of the analysis chamber, sample mounting and then treatments in the analysis chamber. The descriptions of the processes and their implications are intended as an aid for the analyst in understanding the reporting requirements for the specialized sample-handling conditions and approaches required for analyses by techniques such as Auger electron spectroscopy (AES), secondary-ion mass spectrometry (SIMS), and X-ray photoelectron spectroscopy (XPS). The methods described are also applicable for other analytical techniques, such as total reflection X-ray fluorescence spectroscopy (TXRF), low energy electron diffraction (LEED), some types of scanning probe microscopy (SPM) including atomic force microscopy (AFM) and scanning tunnelling microscopy (STM), ultra-violet photoelectron spectroscopy (UPS) and medium- and low-energy ion scattering (MEIS and LEIS [also called ion surface scattering, ISS]) that are sensitive to surface composition.

This document does not ~~define~~specify the nature of instrumentation, instrument conditions (e.g., calibration or vacuum quality), or operating procedures required to ensure that the analytical measurements described have been appropriately conducted.

2 Normative references

The following documents are referred to in the text in such a way that some of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO_18115-1, *Surface chemical analysis — Vocabulary — Part 1: General terms and terms used in spectroscopy*

ISO_18115-2, *Surface chemical analysis — Vocabulary — Part 2: Terms used in scanning-probe microscopy*

3 Terms and definitions

For the purposes of this document, the terms and definitions given in ISO 18115-1 and ISO 18115-2 apply.

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ISO and IEC maintain terminology databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at <https://www.iso.org/obp>
- IEC Electropedia: available at <https://www.electropedia.org/>

4 Symbols and abbreviated terms

AES	Auger electron spectroscopy
AFM	atomic force microscopy
EELS	electric energy-loss spectroscopy
ESCA	electron spectroscopy for chemical analysis (alternate name for XPS)
FIB	focused ion beam

ID [Identification](#)

ID [Identification](#)

ISS ion-scattering spectroscopy

LEED low-energy electron diffraction

LEIS low energy ion-scattering

MEIS medium energy ion-scattering

PTFE polytetrafluoroethylene

SIMS secondary ion mass spectrometry

SPM scanning probe microscopy

STM scanning tunneling microscopy

TXRF total reflection X-ray fluorescence spectroscopy

UPS ultraviolet photoelectron spectroscopy

XPS X-ray photoelectron spectroscopy

5 Provenance information to be collected or retained

5.1 Information record

[Clause 5](#) deals with a sample information record that includes the relevant sample history, sample handling requirements, and analysis objectives. This information is usually provided by those requesting analysis. If it is not provided with the sample, it will need to be created (see [Clause 5.2](#)).

Surface analysis is usually undertaken to collect useful information relevant to a sample for a specific reason at specific stages during the lifetime or history of the material. To assess the reliability and usefulness of the analysis, it is important to retain as many relevant sample history and handling details that are available to maintain the provenance of the sample and data related to them.

Samples are often provided to an analyst by someone seeking information about one or more samples. Such samples should arrive with a history and the information described in ISO 20579-[part 1](#) about the nature of

the sample, the analysis objective, and any special requirements (ISO 20579-~~part 1: Clause 2024~~, 5.2), and with unique sample identifiers (IDs) and information, including dates, about previous handling, storage, and processing as relevant to the analysis objectives (ISO 20579-~~part 1: Clause 2024~~, 5.3).^[2] Information about different types of analysis objectives and the implications for sample handling ~~is~~are provided in ISO 20579-~~part 1: 2024~~, Annex A and summarized in ~~Annex B~~Annex B of this document. Detailed information records are especially important for nano-objects as described in ISO 20579-~~part 4: 2018~~, Clauses ~~4~~ and 5.^[4]

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Information that an analyst shall record and add to the information record regarding the further preparation and handling of samples for surface analysis are described in ~~Clause 6~~ of this document. This information, along with data collected becomes part of the information record that provides the history of the physical and chemical processes used on a sample that would allow assessment and replication of the measurement. Appropriate information to be retained and passed along with analysis information will vary depending on the nature and history of the sample and the analysis objectives as described in ~~Clause 6~~Clause 6. Dates should be provided whenever possible throughout the provenance record.

5.2 Verification or generation of sample information and analysis objectives

When an analyst receives one or more specimens, a necessary step is to examine the sample documentation, or establish it (with the owner) if not provided, including the nature of the sample(s), clear sample IDs, and appropriate analysis objectives. It is also important to determine if the samples have been handled properly to enable appropriate surface analysis and if relevant, that information about specific analysis areas or regions of analysis interest have been identified and documented.

If this information was not provided, the analyst shall assemble as much information as possible to establish a complete information record and analysis plan that will determine the sample handling and preparation necessary to obtain the desired information from the sample(s).

A visual inspection (documented) of each sample is important to verify information, sample condition and identification of any special features or problems such as fingerprints, adhesive, unexpected particles, or contaminants.

6 Information about sample handling and preparation for analysis to be documented and added to the sample information record

6.1 General

Information about the following topics shall be recorded and reported as part of the sample information record.

6.2 Adherence or exceptions to the general sample handling requirements

To maintain the stringent cleanliness required for meaningful surface analysis the general sample handling protocols listed below and in ~~A.1.1 A.1.1~~ and ~~B.3.2 B.3.2~~ shall be followed.^[7]^[11] These generic requirements also appear in ISO 20579-~~part 1, 2024~~, B.2.2 and B.2.3. Any exceptions or deviations shall be documented. Justification for these measures and further details are provided in the Annexes of ISO 20579-~~part 1~~ and this document. ~~Annex A~~ of this document gives some additional details about general considerations for sample handling to minimize contamination and is summarized here.

Avoid touching the sample surface to be analysed with any material, including tools, hands, and containers, as well as adventitious contact from gases, liquids, particulates, or outgassing materials near the surface or present in the environment. If possible, air sensitive samples should be introduced using a glove box or a transfer vessel and documented in the reporting.